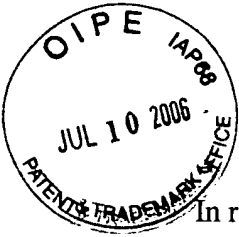


03500.109446.

PATENT APPLICATION

IFW



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
:)
MASAKI MIZUTANI, et al.)
:) Group Art Unit: 2812
Application No.: 10/563,115)
:)
Intl. Filing Date: May 17, 2005)
:)
371(c) Date: January 3, 2006)
:)
For: SILICON LAYER PRODUCTION)
METHOD AND SOLAR CELL :
PRODUCTION METHOD) July 7, 2006

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the document listed on the enclosed Form PTO-1449. A copy of the listed document is enclosed.


The listed document is discussed at page 5 of the specification.

This Information Disclosure Statement is being filed before the issuance of a first Office Action on the merits. Therefore, no fee under 37 C.F.R. § 1.97(c)(2) is believed due. Nevertheless, the Commissioner may charge Deposit Account No. 06-1205, should any fee be due for filing this paper.

Applicants request that the above information be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be initialed and returned indicating that such information has been considered.

Applicants' undersigned attorney may be reached in our Costa Mesa, California office at (714) 540-8700. All correspondence should continue to be directed to our below-listed address.

Respectfully submitted,

A handwritten signature in black ink, appearing to read "Damond E. Vadnais", is written over a horizontal line.

Damond E. Vadnais
Attorney for Applicants
Registration No.: 52,310

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